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Sheet 1 of 1

Form PTO-1449 (REV. 1/06)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 126918		APPLICATION NO. New U.S. National Stage of PCT/GB2004/003402	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)				APPLICANTS Magdalena LEWICKA-SCHAFER			
				FILING DATE February 3, 2006		GROUP	

U.S. PATENT DOCUMENTS				
Examiner Initials	Cite No.	Document Number	Date	Name
/AC/	1	US 2003/0084584 A1	5/8/2003	OSTERSTOCK
	2	US 5,075,130	12/24/1991	REEBER et al.
	3	US 5,422,322	6/6/1995	CHEN et al.
	4	US 4,153,998	5/15/1979	MCMURTRY
	5	US 4,084,323	4/18/1978	MCMURTRY
	6	US 5,656,563	8/12/1997	CHEN et al.
/AC/	7	US 5,976,429	11/2/1999	CHEN et al.

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Document Number	Date	Country	With English Abstract	With English Translation
/AC/	8	EP 1 079 201 A2	2/28/2001	EUROPE		
	9	DE 202 07 100 U 1	9/5/2002	GERMANY		
	10	EP 0 620 252 A1	10/19/1994	EUROPE		
	11	WO 03/039233 A2	5/15/2003	WIPO		
	12	GB 2 243 688 A	11/6/1991	GREAT BRITAIN		
/AC/	13	EP 0 746 532 B1	9/15/1999	EUROPE		

OTHER DOCUMENTS		
Examiner Initials	Cite No.	(Including Author, Title, Date, Pertinent Pages, etc.)
/AC/	14	KUSUNOSE et al., "Machinability of Silicon Nitride/Boron Nitride Nanocomposites," Journal of the American Ceramic Society, vol. 11, no. 85, pp. 2689-2695, XP001141572 (November 2002)
/AC/	15	KUSUNOSE et al., "Fabrication and Microstructure of Silicon Nitride/Boron Nitride Nanocomposites," Journal of the American Society, vol. 85, no. 11, pp. 2678-2688 (November 2002)
/AC/	16	ERDEMIR et al., "Self-Replenishing Solid Lubricant Films on Boron Carbide," Surface Engineering, vol. 15, no. 4, pp. 291-295 (1999)

EXAMINER /Amy Cohen/	DATE CONSIDERED 03/30/2007
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Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Date: February 3, 2006